Microfabricated Surface Electrode Ion Traps

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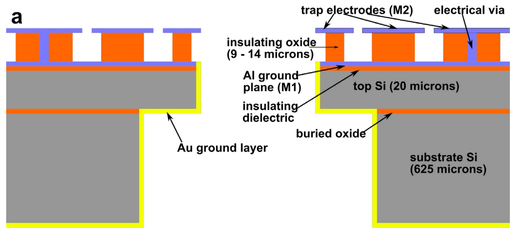
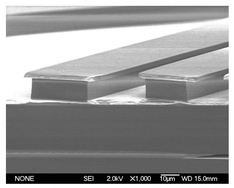
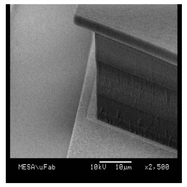
Surface Electrode Ion Microtrap Fabrication





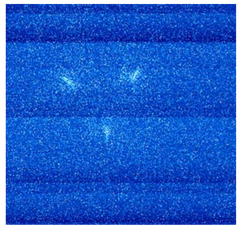


Precision dielectric set-back

- 5 linear traps tested in 3 different groups with Ca^+ and Yb^+ [arXiv:1008.0990v1].

Junction trap

- Trapped single and multiple ions
- Shuttled ion single axis (830 μm) - 10^5 repeat fidelity
- Shuttled to each leg of junction 10^6 times without ion loss
- ***Successful junction shuttling in two different Y-junction models***



Time lapse image in the junction - a single ion moving up each leg

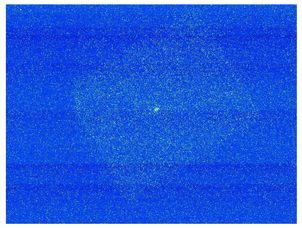
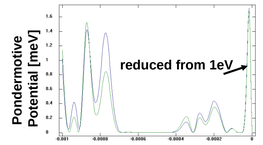
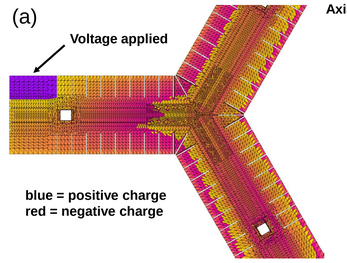
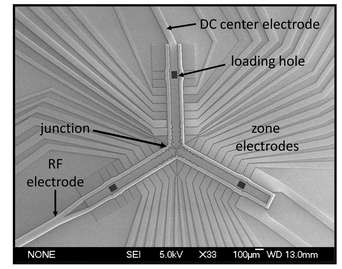


Image of a trapped ion - loading hole is illuminated by the oven

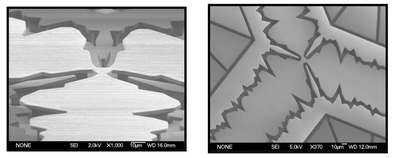




(a) Finite element model of charge distribution
(b) Design minimized RF potential axial variation
(c) Electrode voltages for shuttling past shorted electrode



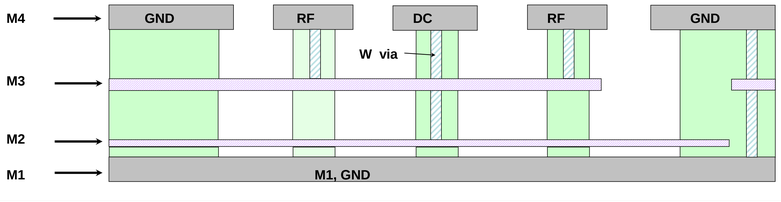
With 4 metal levels, all electrode routing will be invisible to ion.



4 level metal

Development - Four metal layer process:

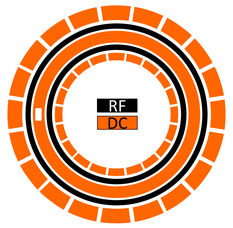
- Routing of RF and Crossing of DC electrodes is required away from trapping regions
- Allows for interior RF/DC electrodes to be wired (e.g. ring trap)
- Simplifies simulations by eliminated need to model effect of leads
- DC lead crossings below M4 electrode level and above M1 ground
- RF routing in stripline configuration with RF, below trap electrode level

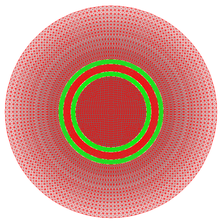


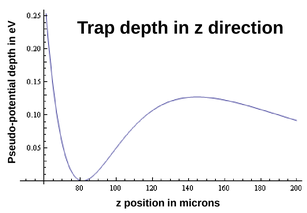
Ring Traps and Cavity QED – MQCO collaboration

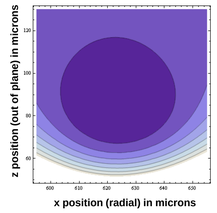
Ring Trap

- Requires 4 metal level fabrication
- CPO simulation for barium ions
- RF drive frequency of 40 MHz, 300 V amplitude
- 624 micron radius ring of ions
- 60 μm wide RF electrodes, 100 μm separation



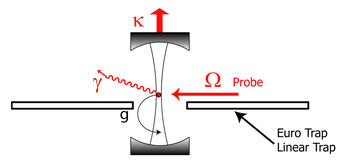


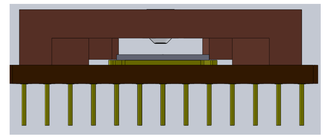


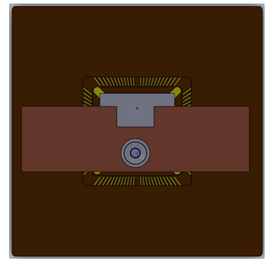


Cavity QED Trap

- Integrate with linear trap
- Sandia will test with Yb^+
- Loading slot custom designed for cavity thru-hole
- Mount registered to Si chip
- Goal of $C_1 > 0.2$ for Yb^+ and 10% light collection efficiency

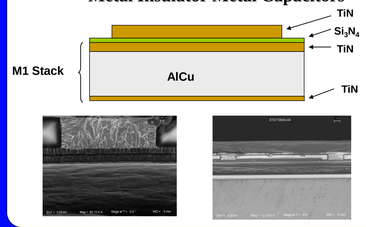






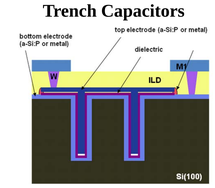
On chip capacitors

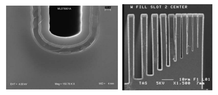
Metal Insulator Metal Capacitors



- Higher capacitance density for trench capacitors (94.3 fF/μm² vs. 1.3 fF/μm²).
- Capacitors are located within microns of DC electrode.
- 1nF trench capacitor is about the size of an electrode

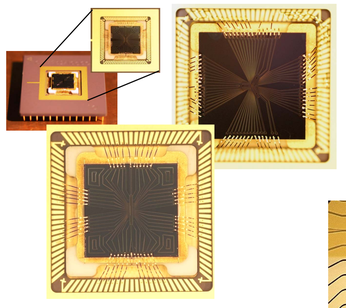
Trench Capacitors



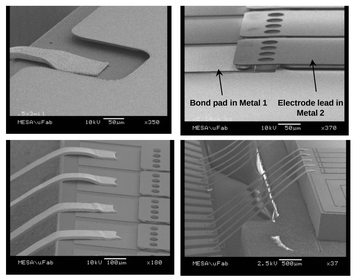


Ion Trap Packaging

Commercial off-the-shelf Kyocera 100 pin package
- Plug-&-Play design



Over-coating capability of trap – Au and Al see in figure



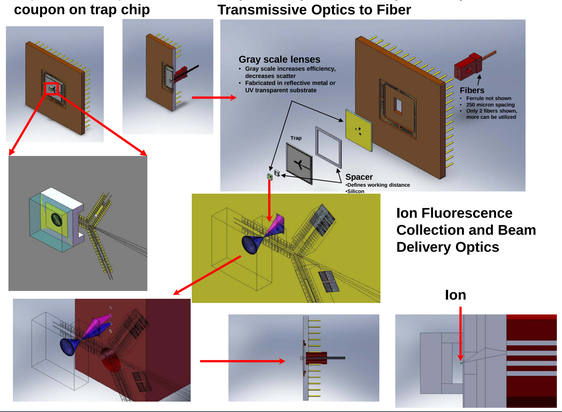
Multi-level metalization and low profile wire bonding minimize interference with lasers

Integrated Diffractive and Micro Optics

- Can realize transmissive and/or reflective integrated optics
- Off-axis capability → dense optic arrays with 100% fill factor
- Entire lens set is aligned to ions and in-vacuum fiber connector
- Maximum photon interaction in a simple, robust configuration

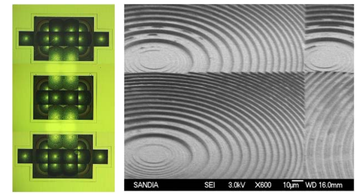
Top reflective optic coupon on trap chip

Trap with Top Reflective Optics Coupon and Back Transmissive Optics to Fiber

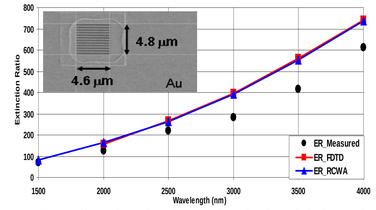


Existing Sandia Capabilities

- Diffractive Optical Element (DOE) arrays in fused silica with 100% fill factor
- Fused silica and lithium fluoride polarizers with extinction ratios > 100:1
- Microwaveplates with 9.4º rms variation across broad MWIR band



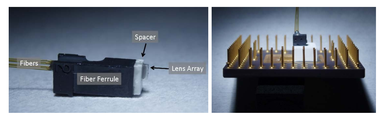
Sandia DOE array in fused silica with 100% fill-factor Optical microscope (L) and SEM (R) images



Broadband extinction ratio of microfabricated polarizer in fused silica

Milestones

- Fabricated 8-level F/1 lenses with focused spot diameters < 1micron at 397 nm
- Multi-fiber feed-throughs and in-vacuum connectors survive bake-out and maintain ultra-high vacuum



G.R. Brady et al. arXiv:1008.2977v1